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| INFORMATION DISCLOSURE STATEMENT BY APPLICANT | | | | Complete if Known | |
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| | | | | First Named Inventor | OGAWA |
| | | | | Group Art Unit | N/A |
| | | | | Examiner Name | N/A |
| Sheet | 1 | of | 1 | Attorney Docket Number | N29748500S |

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| U.S. PATENT DOCUMENTS | | | | | | |
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| TT | | JP | 2000-049222 | | Hitachi Ltd. | 02-18-2000 | |
| TT | | US | 5,981,356 | | Integrated Device Technology, Inc. | 11-09-1999 | |
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| OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS | | |
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| Examiner Initials | Cite No. ¹ | Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published. |
| TT | | English Bibliography and Abstract of JP 2000-049222 (noted above). |
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|-----------------------|-------------------|-----------------|----------|
| Examiner Signature | <i>Thien Tran</i> | Date Considered | 04-16-02 |
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¹Unique citation designation number. ²See attached Kinds of U.S. Patent Documents. ³Enter Office that issued the document, by the two letter code (WIPO Standard ST.3). ⁴For Japanese documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ⁶Applicant is to place a check mark here if English language Translation is attached.